

DEA ALPHA 2.0

BRIDGING THE PRICE / PERFORMANCE GAP IN GANTRY CMMs

An innovative product line of cost-effective, medium-capacity multisensor gantry CMMs, the DEA ALPHA 2.0 combines high throughput and high accuracy with excellent operating reliability and minimal maintenance. DEA ALPHA 2.0 is available in two versions, DEA ALPHA 2.0 Classic, and DEA ALPHA 2.0 Performance.

DEA ALPHA 2.0 Classic is an all-purpose flexible CMM for the dimensional inspection of large castings and machined parts. Equipped with a high-productivity 3D scanning laser head and continuous servo wrist options, DEA ALPHA 2.0 Classic can rapidly acquire millions of data points from complex contoured shapes, and is the ideal system for die and mould manufacturing support.

DEA ALPHA 2.0 Performance is a high-performing gantry CMM that, thanks to a high-rigidity silicon carbide spindle and a sophisticated multisensor temperature compensation system, guarantees high accuracy and ease of use under all operating conditions.

All DEA ALPHA 2.0 models can be supplied equipped with optional bellows and covers, which offer machine protection for airborne shop contaminants.

